<u>IN THE UNITED STATES PATENT AND TRADEMARK OFFICE</u>

IN RE APPLICATION OF: Aelan MOSDEN et al. :

: ATTENTION

SERIAL NO.: 10/801,571

: LICENSING & REVIEW

FILED: March 17, 2004

METHOD AND SYSTEM FOR TREATING A HARD MASK TO IMPROVE ETCH

CHARACTERISTICS

PETITION FOR LICENSE FOR FOREIGN FILING UNDER 35 U.S.C. 184 - EXPEDITED HANDLING

COMMISSIONER FOR PATENTS Alexandria, VA 22313

SIR:

For:

Applicant hereby respectfully petitions the Patent Office under 37 C.F.R. 5.12(b) and 5.13 for a license under 35 U.S.C. 184 to permit petitioner to file or cause to be filed in foreign countries applications corresponding to the above-identified application. A copy of the specification is attached hereto.

It is believed that no section of 35 U.S.C. 181 is applicable.

The required fee set forth in 37 C.F.R. 1.17(h) of \$130.00 is also enclosed herewith.

EXPEDITED PROCESSING IS REQUESTED.

强和 华丽东郑斯瓦 Please telephone Ms. Bette Snyder, at (703) 412-6237 when the license has been granted 1. 9. 00 to and is ready to be picked up and a messenger from our office will be immediately dispatched.

Respectfully submitted,

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